

Supplementary Information

An electric-field-dependent drop selector

Jinlong Yang¹, Dehui Wang¹, Hailong Liu², Linxian Li³, Longquan Chen⁴, Hong-Ren Jiang^{5}, and Xu Deng^{1*}*

¹Institute of Fundamental and Frontier Sciences, University of Electronic Science and Technology of China, Chengdu, China

²School of Energy and Power Engineering, Jiangsu University, Zhenjiang, China

³ Ming Wai Lau Centre for Reparative Medicine, Karolinska Institute, Hong Kong

⁴School of Physics, University of Electronic Science and Technology of China, Chengdu, China

⁵Institute of Applied Mechanics, National Taiwan University, Taipei, 106, Taiwan

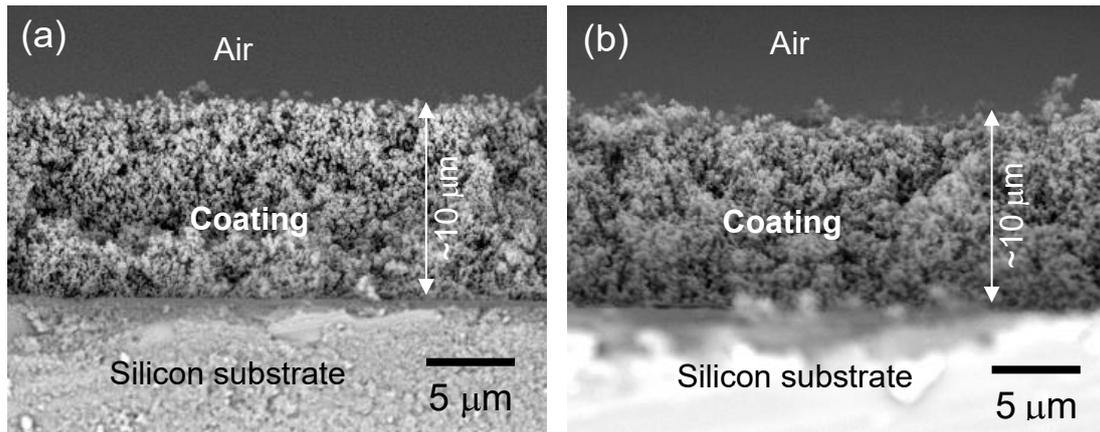


Figure S1. SEM image of a cross section of superhydrophobic coating scanned from two samples (a and b). The thickness of the porous structures is controlled consistently at $\sim 10 \mu\text{m}$.

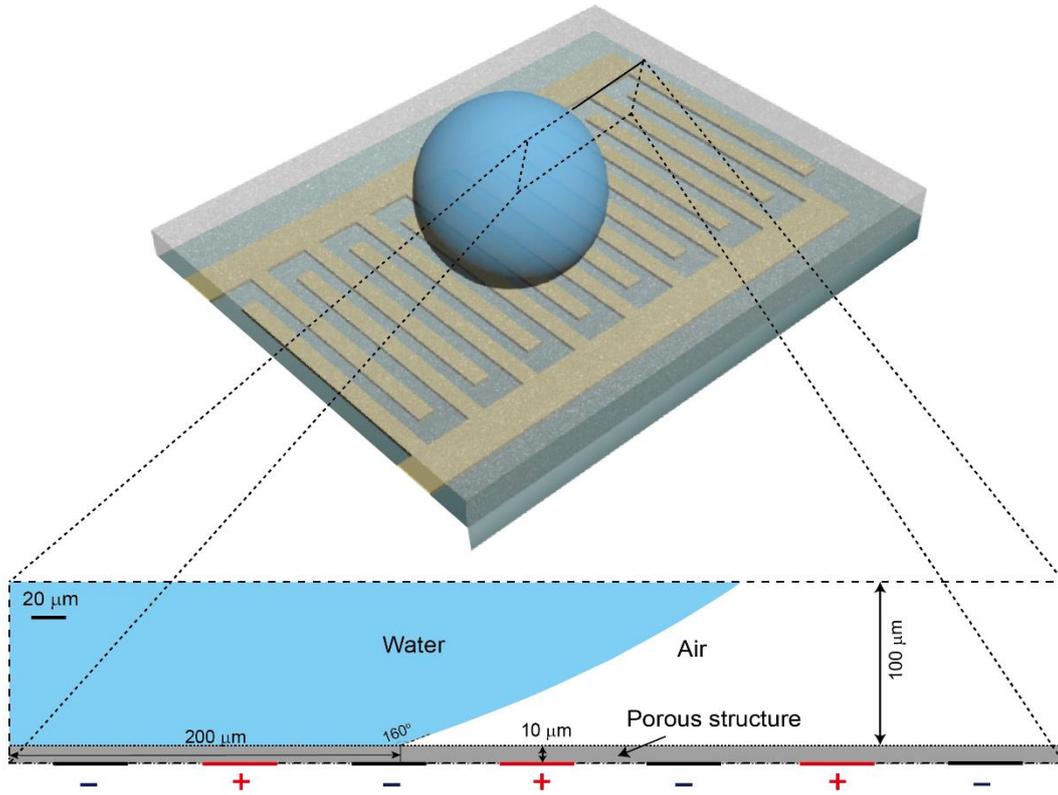


Figure S2. Computational domain. A vertical two-dimensional domain ($550 \times 110 \mu\text{m}$) at the center of the drop is selected as the region of interest. The electric field is assumed symmetric so that only half of the domain is considered in the analysis. Current continuity condition is applied at air-water, air-substrate, and water-substrate interfaces. Symmetric condition is applied at the symmetric axis and insulation condition is applied at the rest of boundaries of the domain. The constant potential conditions are applied at the electrodes.

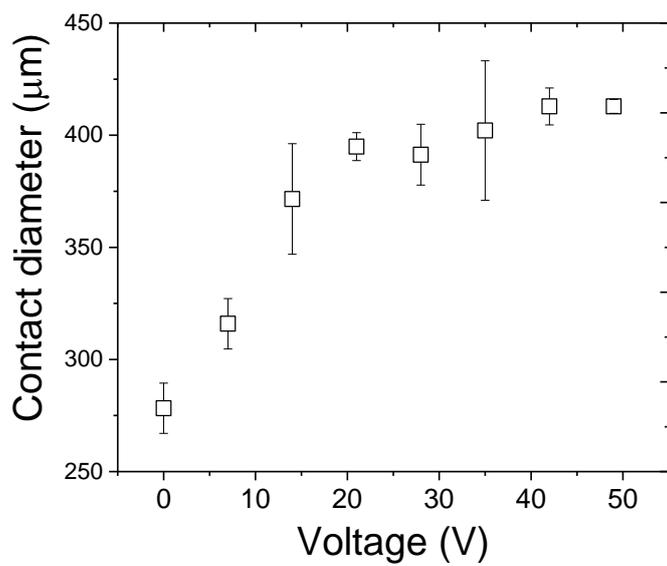


Figure S3. The measured contact diameter as a function of applied voltage.

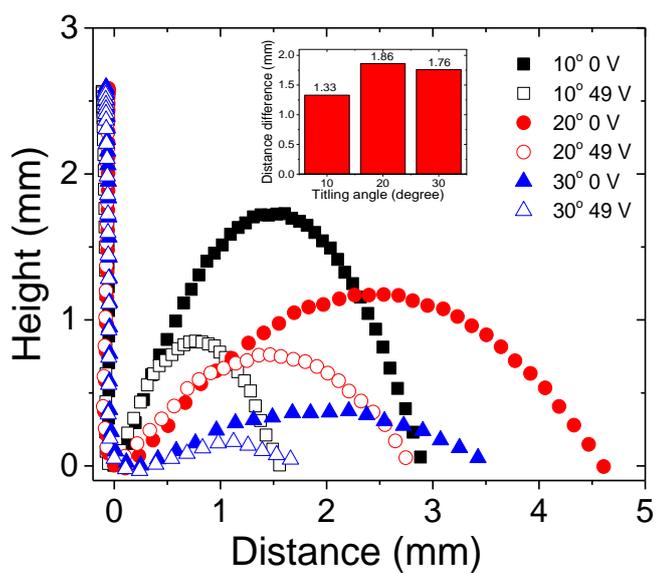


Figure S4. Drop bouncing distance as a function of the applied voltages under three tilting angles. Inset is the difference of distance when drop bounds on the three tilting angles at the same releasing height. It is concluded that the optimized tilting degree to generate the largest distance difference is 20°.

Table S1. The properties of materials used in the simulation.

	Electrical conductivity (S/m)	Dielectric constant
Air	1×10^{-9}	1
Porous structure	1×10^{-9}	2
Water	5.5×10^{-6}	80

Video S1. Comparison of adhesion force measured at voltages of 0 V and 42 V.

Video S2. Comparison of drop rebounding at voltages of 0 V and 42 V at releasing height of 3 mm.

Video S3. Comparison of drop rebounding at voltages of 0 V and 42 V at releasing height of 9 mm.

Video S4. Reproducibility of separating drops under electric field.